Conversion of Thermal ALD to Plasma Assisted ALD

- Conversion of commercial and home built ALD systems
- 300 and 600 watt systems, higher on request. No water cooling.
- 4” and 8” wafer diameter, plus larger on request
- Oxides, nitrides, other
- **Hollow Cathode Technology with Low oxygen contamination**
- Cost effective
- High electron density > 10^{12} \text{ cm}^{-3} for some conditions.
- Wide range of operating pressures (eg. from < 10 \text{ mTorr} to > 5 \text{ Torr}).
- Improved growth per cycle for many material systems
Meaglow has several solutions for the conversion of thermal ALD with its hollow cathode plasma technology. Contact us at info@meaglow.com or phone +1 807 252 4391.

Related Papers:

For more information on Meaglow Ltd or its hollow cathode plasma sources, visit our website www.meaglow.com or contact us at info@meaglow.com.